

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:
Osamu Nozawa et al.
Serial No.: 10/771,997
Filed: February 4, 2004
For: Manufacturing Method And Apparatus of
Phase Mask Shift Blank
Examiner: Rodney Glenn McDonald
Confirmation No.: 4072
Art Unit: 1753

AMENDMENT G (AFTER FINAL)

Commissioner of Patents
P. O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Applicants have the following response to the Final Rejection of April 26, 2007, a RCE and a three month extension of time being submitted herewith.

Please amend the above-identified application as follows: